

**Science Center Rockwell International Corporation** 1049 Camino Dos Rios P.O. Box 1085 Thousand Oaks, California 91358

(805) 373-4545



ිට් වේ.ට්ට කුරුවට ඉදිනිවීම කියල් විය දිදිවීම වීම වැනිවා කියල් විය. මෙයල් වෙන්නේ කියල් විය. වේ. වේ. වෙන මෙයල් වෙන කියල් විය. වෙන මෙයල් වෙන්නේ සිටුවේ වෙන මෙයල් වෙන්නේ සිටුවේ වෙන ව



August 11, 1992

In reply refer to GO 71033

Scientific Officer . **Materials Division** Office of Naval Research 800 No. Quincy Street Arlington, VA 22217-5000

Attention:

Dr. Wallace A. Smith

Subject:

Electrodeposition of High Temperature Superconductors"

For period 04/01/92 through 06/30/92 Contract No. N00014-90-C-0225

**SC71033.QRDSR** 

Enclosed please find subject report.

ROCKWELL INTERNATIONAL CORP. Science Center

D. Morgan Tench

D. Marto

Principal Investigator

cs:

Director, Advanced Research Projects Agency 3701 No. Fairfax Drive Arlington, VA 22203-1714

Attn: DSO/Frank Patten - 1 copy

Scientific Officer - 3 copies

Director.

Naval Research Laboratory

Attn: Code 2627

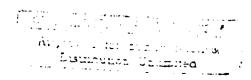
Washington, DC 20375 - 1 copy

Defense Technical Information Ctr. Bldg. 5, Cameron Station Alexandria, VA 22034-6145

- 2 copies

Strategic Analysis 4001 N. Fairfax Drive, No. 765

Arlington, VA 22203 Attn: Mark Davis - 1 copy



**Science Center Rockwell International Corporation** 1049 Camino Dos Rios P.O. Box 1085 Thousand Oaks, California 91358 Rockwell International

Dtic quality inspected Availability Codes Avail and/or Dist Special

Office of Naval Research 800 North Quincy Street Arlington, VA 22217-5000

Attention:

Dr. Wallace A. Smith

Subject:

Quarterly R&D Status Report No. 7

(805) 373-4545

"Electrodeposition of High Temperature Superconductors"

For period 04/01/92 through 06/30/92 Contract No. N00014-90-C-0225

SC71033.QRDSR

## PROGRAM SUMMARY

The overall objective of this project is to develop a process for direct electrodeposition of Y-Ba-Cu superconducting oxides from a molten salt at relatively low temperatures (300-550°C). The approach entails establishing a sequence of electrochemical steps for the layered deposition of Y, Ba and Cu oxide species from a eutectic Na-K nitrate melt.

## PROGRAM STATUS

No work was performed during this reporting period since the required inert atmosphere glove box had been diverted for use on another project (because of the delay in receiving incremental funding). This equipment is now available for the present program and work is again proceeding.

## **ACCOMPLISHMENTS**

Not applicable.

PROBLEM AREAS

None.

GOALS FOR NEXT REPORTING PERIOD

2-23532

92 8 24 038 Future work will focus on developing and evaluating promising schemes for electrodeposition of Y-Ba-Cu HTSC materials. Initial studies will be directed toward evaluating the molten salt electrochemical equivalent of molecular beam epitaxy. In this case, the electrode voltage is maintained just positive of that required for Ba oxide deposition, and monolayer amounts of Cu and Y are injected (by electrodissolution of individual metal electrodes) and electrodeposited in sequence. A cell of very small volume is used to ensure that complete deposition of the injected metal occurs in a short time. Incorporation of Ba oxide layers should occur in proper sequence by underpotential compound formation. This simple straightforward approach will be investigated thoroughly before more complicated deposition schemes are considered.

ROCKWELL INTERNATIONAL CORP. Science Center

D. M. Tench

Principal Investigator

D. M. - Tend